505886683 01/28/2020

PATENT ASSIGNMENT COVER SHEET

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SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	ASSIGNMENT

CONVEYING PARTY DATA

Name	Execution Date
HAN WANG	05/30/2017
QI XIE	05/15/2017
DELPHINE LONGRIE	05/15/2017
JAN WILLEM MAES	05/15/2017
DAVID DE ROEST	05/15/2017
JULIAN HSIEH	05/22/2017
CHIYU ZHU	06/01/2017
TIMO ASIKAINEN	06/01/2017
KRZYSZTOF KACHEL	05/15/2017
HARALD PROFIJT	05/15/2017

RECEIVING PARTY DATA

Name:	ASM IP HOLDING B.V.
Street Address:	VERSTERKERSTRAAT 8
City:	ALMERE
State/Country:	NETHERLANDS
Postal Code:	1322 AP

PROPERTY NUMBERS Total: 1

Property Type	Number
Application Number:	16773064

CORRESPONDENCE DATA

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ATTORNEY DOCKET NUMBER: ASMMC.121P1C2

NAME OF SUBMITTER:	ANDREW N. MERICKEL	
SIGNATURE:	/Andrew N. Merickel/	
DATE SIGNED:	01/28/2020	
	This document serves as an Oath/Declaration (37 CFR 1.63).	
Total Attachments: 11		
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Application Data Sheet filed previously or concurrently

Docket No.: ASMMC.121P1 Page 1 of 11

Title: SELECTIVE DEPOSITION OF ALUMINUM AND NITROGEN CONTAINING MATERIAL

Inventors: Han Wang, Qi Xie, Delphine Longrie, Jan Willem Maes, David de Roest, Julian Hsieh, Chiyu Zhu, Timo Asikainen, Krzysztof Kachel, and Harald Profijt

Declaration

This Declaration is directed to the application identified above that:

Was filed **February 14, 2017** as U.S. or International Application No. **15/432,263** and incorporating any amendments made thereto prior to the signature date of this Declaration.

As a named inventor, I declare that:

The above-identified application was made or authorized to be made by me.

I believe that I am the original inventor or an original joint inventor in the application.

I hereby acknowledge that any willful false statement made in this declaration is punishable under 18 USC 1001 by fine or imprisonment of not more than five (5) years, or both.

I have reviewed and understand the contents of the above-identified application, including the claims, as amended by any amendment.

I acknowledge the duty to disclose information which is material to patentability as defined in 37 CFR 1.56.

Assignment from Inventors

WHEREAS, above-identified inventors (individual(s) hereinafter "ASSIGNOR") invented certain new and useful improvements, technology, inventions, developments, ideas, ornamental designs, or discoveries, and hereby assign or are under an obligation to assign to the below identified Assignee the above-titled application (collectively hereinafter referred to as the "Work") for which an application for Letters Patent in the United States (identified above) has been prepared for filing with the United States Patent and Trademark Office (hereinafter the "Application").

AND WHEREAS, **ASM IP Holding B.V.**, with its principal place of business at Versterkerstraat 8, Almere, 1322 AP, Netherlands (hereinafter the "ASSIGNEE"), desires to acquire the entire right, title, and interest in and to the Application and the Work.

NOW, THEREFORE, for good and valuable consideration of which receipt is hereby acknowledged, ASSIGNOR hereby acknowledges that ASSIGNOR has sold, assigned, transferred and set over, and by these presents does hereby sell, assign, transfer and set over, unto said ASSIGNEE, its successors, legal representatives and assigns, the entire right, title, and interest throughout the world in the Application and the Work, including all Patent Properties filed or issued upon the Application and the Work; where "Patent Properties" include, but are not limited to:

all provisional applications relating thereto;

all nonprovisional applications claiming priority to aforementioned provisional(s) and/or the present Application, including, all divisions, continuations, continuations-in-part, and reissues, and all Letters Patent of the United States which may be granted thereon and all reissues and extensions thereof; and

all rights of priority under International Conventions and any related Letters Patent which may hereafter be granted or filed in any country or countries foreign to the United States, all extensions, renewals and reissues thereof.

Application Data Sheet filed previously or concurrently

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Title: SELECTIVE DEPOSITION OF ALUMINUM AND NITROGEN CONTAINING MATERIAL

Inventors: Han Wang, Qi Xie, Delphine Longrie, Jan Willem Maes, David de Roest, Julian Hsieh, Chiyu Zhu, Timo Asikainen, Krzysztof Kachel, and Harald Profijt

ASSIGNOR hereby acknowledges the ASSIGNEE as the Applicant for all aforementioned Patent Properties, and authorizes and requests the Commissioner of Patents of the United States, and any Official of any country or countries foreign to the United States, whose duty it is to issue patents on applications as aforesaid, to issue all related Letters Patent to the ASSIGNEE, its successors, legal representatives and assigns, in accordance with the terms of this instrument.

AND ASSIGNOR DOES HEREBY sell, assign, transfer, and convey to ASSIGNEE, its successors, legal representatives, and assigns all claims for damages and all remedies arising out of any violation of the rights assigned hereby that may have accrued prior to the date of assignment to ASSIGNEE, or may accrue hereafter, including, but not limited to, the right to sue for, collect, and retain damages for past infringements of said Letters Patent before or after issuance.

AND ASSIGNOR DOES HEREBY covenant and agree that ASSIGNOR will communicate to said ASSIGNEE, its successors, legal representatives and assigns, any facts known to ASSIGNOR respecting the Work, and testify in any legal proceeding, assist in the preparation of any other Patent Property relating to the Application and the Work or any improvements made thereto, sign/execute all lawful papers, authorize the filing of and execute and make all rightful oaths and/or declarations in connection with the Application and the Work including any improvements made thereto, any patent applications filed therefrom, and any continuing application filed from any of the aforementioned applications, and generally do everything possible to aid the ASSIGNEE, its successors, legal representatives and assigns, to obtain and enforce proper patent protection for the Work in all countries.

Legal Name of inver	tor: Han Wang				
Signature:	Just	I M	Date:	5-30-	2017
W	Witnessed by:itness Name (printed):	Dali	Shao		

Docket No.: ASMMC:12	1 P1		Page 3 of 11
Tille: SELECTIVE DEP	IIE: SELECTIVE DEPOSITION OF ALUMINUM AND NITROGEN CONTAINING MATERIAL		
	i Xie, Delphine Long inen, Krzysztof Kach	rie, Jan Willem Maes, David de Ro el, and Harald Profijt	est, Julian Hsieh, Chiyu
e i saat i meet meetingid magaan di migaa			and the state of t
Legal Name of invento	r: Qì Xie		
Signature	Ox she	Date:	May 15, 2017
	Witnessed by:	- Augustin	
Witne	ess Name (printed):	Dicter Pleasery	

Application Data Sheet filed previously or concurrently

Docket No.: ASMMC.121P1 Page 4 of 11

Title: SELECTIVE DEPOSITION OF ALUMINUM AND NITROGEN CONTAINING MATERIAL

Inventors: Han Wang, Qi Xie, Delphine Longrie, Jan Willem Maes, David de Roest, Julian Hsieh, Chiyu Zhu, Timo Asikainen, Krzysztof Kachel, and Harald Profijt

Legal Name of inventor: Delphine Longrie

Signature: Date: 5/65/3/3

Witnessed by:

Witness Name (printed):

Docket No.: ASMMC 121P1	Page 5 of 11
Title: SELECTIVE DEPOSITION OF ALUMINUM	AND NITROGEN CONTAINING MATERIAL
Inventors: Han Wang, Qi Xie, Delphine Longrie, Ja Zhu, Timo Asikainen, Krzysztof Kachel, an	an Willem Maes, David de Roest, Julian Hsìeh, Chiyu d Harald Profijt
Legal Name of inventor: Jan Willem Maes	
Signature:	Date: MAY 15, 101
Witnessed by:	and the second s
Witness Name (printed): 1015	ten Dirakulu

Docket No.: ASMMC.121P1					F	age 6 of 11
Title: SELECTIVE DEPOSIT	ION OF ALUMI	NUM AN	ID NITROGEI	I CONTAINII	NG MATERIAL	
Inventors: Han Wang, Qi Xie Zhu, Timo Asikainen				David de Ro	est, Julian Hsi	eh, Chiyu
Legal Name of inventor: Da		ana dagawa da	د د د د د د د د د د د د د د د د د د د	<i>.</i> ;**;**		
Signature:		and a		Date:	15/09	12017
Concern	Witnessed by:	М.	570KH0F	agfli.	<u> </u>	
Witness N	lame (printed):	570	KHOF	. *		

Docket No.: ASMMC,12	:1P1			Page 7 of 11	
Title: SELECTIVE DEPOSITION OF ALUMINUM AND NITROGEN CONTAINING MATER				G MATERIAL	
Inventors: Han Wang, C Zhu, Timo Asika	Qi Xie, Delphine Lo ainen, Krzysztof Ka	ngrie, Jan Willem Maes, [chel, and Harald Profijt	David de Roe	st, Julian Hsieh, Chiyu	
S constitution of the same			·	Name of the second seco	
Legal Name of invento	r: Julian Hsien	. 7 .			
Signature:	///!:	ldruh	Date:	5/22/201	
	/ Witnessed by:	- digopiar 1	Motons	hrta.	
Witne	ess Name (printed)	: Klyohiro	Matsu	shita	

Docket No.: ASMMC,121P1				Pag	je 8 of 11
Title: SELECTIVE DEPOSITI	ON OF ALUMINUM A	ND NITROGEN CO	NTAINING	MATERIAL	
Inventors: Han Wang, Qi Xie, Zhu, Timo Asikainen,			d de Roes	t, Julian Hsieh	, Chiyu
			· · · · · · · · · · · · · · · · · · ·		×
Legal Name of inventor: Ch	iyu Zhu				
Signature:			Date: _	61 - Ju	<u>4-20</u> 1
ţ	Nitnessed by:	Spot Sun on Con			
Witness No	ime (orinled):	MANNING	1400	rae.	

Docket No.: ASMMC.121P1	Page 9 of 11
Title: SELECTIVE DEPOSITION OF ALUMINUM AND NI	TROGEN CONTAINING MATERIAL
Inventors: Han Wang, Qi Xie, Delphine Longrie, Jan Willer Zhu, Timo Asikainen, Krzysztof Kachel, and Harak	
Legal Name of inventor: Timo Asikainen	
Signature: TSL ASL	Date: <u>7,6.</u> 261구
Witnessed by:	Management of the second
Witness Name (nrinted):	MAN GUSTARI

Application Data Sheet filed previously or concurrently

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Title: SELECTIVE DEPOSITION OF ALUMINUM AND NITROGEN CONTAINING MATERIAL

Inventors: Han Wang, Qi Xie, Delphine Longrie, Jan Willem Maes, David de Roest, Julian Hsieh, Chiyu Zhu, Timo Asikainen, Krzysztof Kachel, and Harald Profijt

Legal Name of inventor: Krzysztof Kachel

Signature:

Witnessed by:

Witness Name (printed):

Application Data Sheet filed previously or concurrently

Docket No.: ASMMC.121P1

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THE. SELECTIVE DEPOSITION OF ALUMINUM AND NITROGEN CONTAINING MATERIAL

Inventors: Han Wang, Gi Xie, Delphine Longne, Jan Willem Maes. David de Roest, Julian Hsieh, Chlyu Zhu, Timo Asikainen, Krzysztof Kachel, and Harald Profiji

Legal Name of inventor: Height Profijt

Signature:

§-

Witness Name (printed):

Date: 15-05-2017

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PATENT

REEL: 051645 FRAME: 0464

RECORDED: 01/28/2020